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		DEST NAMED INVENTOR	ATTORNEY DOCKET NO	CONFIRMATION NO.
APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR		1463
09 903,764	07 13 2001	Taizo Oku		1409
GEORGE A. LOUD 3137 MOUNT VERNON AVENUE ALEXANDRIA, VA 22305			EXAMINER  DANG, TRUNG Q	
ALEXANDRI	A, VA 22505		ART UNIT	PAPER NUMBER
			2823	

DATE MAILED: 10 24 2002

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	No. A	pplicant(s)		
		09/903,764		KU ET AL		
Office Action Summary		Examiner	A	Art Unit		
		: Trung Q. Da		323		
	- The MAILING DATE of this communicat	ion appears on the c	over sheet with the corr	espondence address		
Period fo	r Reply					
THE N - Extendant of the control of	DRIENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA issions of time may be available under the provisions of 3' SIX 46' MONTHS from the mailing date of this communic period for reply specified above is less than thirty (30) day period for reply is specified above, the maximum statuto received within the set or extended period for reply will, eply received by the Office later than three months after set patent ferm adjustment. See 37 CFR 1 704(b)	TION, 7 CFR 1.136(a). In no event lation, bys, a reply within the statuto by period will apply and will a	, however, may a repty be timely ry minimum of thirty (30) days wi expire SIX (6) MONTHS from the stop to hecome ABANDONED.	filed  If be considered timely, mailing date of this communication 35 U.S.C. \$ 133.		
Status		22 2 4 2 2 2 2 2	000			
1)[[	Responsive to communication(s) filed					
2a)		)⊠ This action is n		enaution as to the merits is		
3)	Since this application is in condition for closed in accordance with the practice	or allowance except i e under <i>Ex parte Qu</i>	for formal matters, pros ayle, 1935 C.D. 11, 450	3 O.G. 213.		
-	ion of Claims	nlication				
4)[>	Claim(s) 1-18 is/are pending in the ap	piloation. Hadrown from consid	deration			
	4a) Of the above claim(s) 9-18 is/are w	murawn nom consi	Toración.			
5)	Claim(s) is/are allowed.					
6)[2]	Claim(s) 1-8 is/are rejected.					
7)	Claim(s) is/are objected to.	l/landian ro	auiromont			
	Claim(s) are subject to restriction	on and/or election re	Juliement.			
	ion Papers	Evominer				
9)_	The specification is objected to by the E The drawing(s) filed on is/are: a	Zammer.	objected to by the Exam	iner.		
10)	Applicant may not request that any object	tion to the drawing(s)	be held in abeyance. See	e 37 CFR 1.85(a).		
	The proposed drawing correction filed	on 13 July 2001 is: a	a) approved b) dis	approved by the Examiner.		
11) 🚉	If approved, corrected drawings are requ	ired in reply to this Off	ice action.			
40\□	The oath or declaration is objected to b					
		.,				
Priority	under 35 U.S.C. §§ 119 and 120  Acknowledgment is made of a claim f	or foreign priority un	der 35 U.S.C. § 119(a)	-(d) or (f).		
		or reteight priority and	•			
a	<ul> <li>) All b) Some * c) None of:</li> <li>1. Certified copies of the priority d</li> </ul>	ocuments have bee	n received.			
	1. Certified copies of the priority d	ocuments have bee	n received in Applicatio	on No		
:	2. Certified copies of the priority documents have been received in Application No  3. Copies of the certified copies of the priority documents have been received in this National Stage					
*	application from the Interna	itional Bureau (PCT) for a list of the certi	fied copies not received	d.		
14)	Acknowledgment is made of a claim fo	r domestic priority u	nder 35 U.S.C. § 119(e	) (to a provisional application).		
	a) The translation of the foreign land Acknowledgment is made of a claim for	ruage provisional ap	plication has been rece	eived.		
Attachm						
1 2) T No	itice of References Cited (PTO-892) itice of Draftsperson's Patent Drawing Review (P <sup>T</sup> ormation Disclosure Statement(s) (PTO-1449) Pa	rO-948) per No(s) <u>2</u> .	4) Interview Summary 5) Notice of Informal F 6) Other:	PTO-413) Paper No(s) Patent Application (PTO-152)		
S Pate tian	o Trademark Office	Office Action Cummi	- <del></del> -	Part of Paper No. 8		

Application/Control Number: 09/903.764

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- Applicant's election without traverse of the Group I invention, claims 1-8 in Paper No. 7 is acknowledged.
- 2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

 $\wedge$  person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 3-4, and 6-8 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Maeda et al. (U.S. Pat. No. 5,554,570).

The reference clearly teaches every limitation of the claimed invention in which it discloses a film forming method comprising the steps of: preparing a film forming gas selected from a group consisting of trimethoxysilane (TMS) and tetramethyldisiloxane (TMDSO) and any one oxygen-containing gas selected from a group consisting of O2, N2O, NO2, CO, CO2, and H2O; forming a silicon-containing insulating film by plasma enhanced CVD. See the first and third embodiments and claim 8.

3. Claim 2 is rejected under 35 U.S.C. 102(b) as being anticipated by Saito et al. (JP 08-236518).

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The reference teaches a plasma enhanced CVD method for forming a silicon oxide film, which utilizes trimethoxysilane and a mixed gas of O2 and N2 (see paragraph [0009])

Claim 5 is rejected under 35 U.S.C. 102(b) as being anticipated by Saito et al. (JP 09-134910).

The reference teaches the all the claimed limitation in which it discloses a plasma CVD method for forming a silicon oxide film, which uses trimethoxysilane as a silicon source gas and O2 as an oxidizing gas. The method employs 2 cycle excitation CVD which impresses a RF (13.56 MHZ) to the upper electrode, and impresses a RF (400 kHz) to the lower electrode. See paragraph [0019] and claim 13.

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trung Dang whose telephone number is (703) 308-2548. The examiner can normally be reached on weekdays from 9:00 AM to 5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor. Wael Fahmy, can be reached on (703) 308-4918. The fax phone number for this Group is (703) 305-3432 or (703) 308-7725.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

Trung Dang ⊇rimary Examiner

Jang Jang